

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|---|---|------------------|
| - | 1707 | ((remov\$3 strip\$4) with photoresist) same ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") and (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 14:55 |
| - | 504 | ((remov\$3 strip\$4) with photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") and (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/15 23:58 |
| - | 111 | ((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near3 (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/15 23:58 |
| - | 88 | ((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near2 (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/16 00:09 |
| - | 9 | ((remov\$3 strip\$4) adj photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/15 23:58 |

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|--|----|--|---|------------------|
| | 15 | <p>((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH"))</p> | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/16 00:10 |
| | 6 | <p>((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) not (((remov\$3 strip\$4) adj photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH"))))</p> | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/16 00:10 |
| | 73 | <p>((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near2 (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) not (((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH"))))</p> | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/16 00:26 |

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|---|------|---|---|------------------|
| - | 23 | ((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near3 (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH")) not (((remov\$3 strip\$4) near photoresist) with ((reducing H2 NH3 "H.sub.2" "NH.sub.3" CnH2n+2 CnH2n "C.sub.n H.sub.2n+2" "C.sub.n H.sub.2n" CH4 C2H6 CH32CHCH3 "CH.sub.4" "C.sub.2 H.sub.6" "(CH.sub.3).sub.2 CHCH.sub.3" alkane methane ethane isobutane alkene ethene ethylene propene propylene C2H4 C3H6 "C.sub.2 H.sub.4" "C.sub.3 H.sub.6") near2 (oxidizing oxidation oxygen water carbon adj (monoxide dioxide) O2 H2O CO CO2 "O2.sub." "H.sub.2 O" "CO.sub.2" ROH alcohol EtOH ethanol C2H5OH "C.sub.2 H.sub.5 OH"))) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/06/16 00:26 |
| - | 9 | rf with bias with baffle | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 14:58 |
| - | 10 | rf same bias\$3 with baffle | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 15:00 |
| - | 1 | (rf same bias\$3 with baffle) not (rf with bias with baffle) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 14:59 |
| - | 34 | rf same bias\$3 same baffle | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 15:00 |
| - | 24 | (rf same bias\$3 same baffle) not (rf same bias\$3 with baffle) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 15:00 |
| - | 1 | ((rf same bias\$3 same baffle) not (rf same bias\$3 with baffle)) and quartz near baffle | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/07/21 15:01 |
| - | 9 | {US-6562700-\$ or US-6503840-\$ or US-6534921-\$ or US-6352938-\$ or US-6178660-\$ or US-6031239-\$).did. or (US-20020111041-\$ or US-20020185151-\$).did. or (TW-442916-\$).did. | USPAT; US-PGPUB; DERWENT | 2003/12/09 01:23 |
| - | 7 | ((US-6562700-\$ or US-6503840-\$ or US-6534921-\$ or US-6352938-\$ or US-6178660-\$ or US-6031239-\$).did. or (US-20020111041-\$ or US-20020185151-\$).did. or (TW-442916-\$).did.) and (wet solvent strip\$4 disolv\$3) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:21 |
| - | 6369 | (strip\$3 ash\$3 remov\$3 etch\$3) with (resist photoresist) same (deposit\$4 near (conduct\$3 metal\$3 copper aluminum)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:02 |

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|---|----|--|---|------------------|
| - | 2 | (strip\$3 ash\$3 remov\$3 etch\$3) with (resist photoresist) same (deposit\$4 near (conduct\$3 metal\$3 copper aluminum)) same (without near (solvent wet liquid rins\$3)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:09 |
| - | 1 | (strip\$3 ash\$3 remov\$3 etch\$3) with (resist photoresist) same (deposit\$4 near (conduct\$3 metal\$3 copper aluminum)) same (complet\$3 all) near dry | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:07 |
| - | 71 | (strip\$3 ash\$3 remov\$3 etch\$3) with (resist photoresist) same (without near (solvent wet liquid rins\$3)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:08 |
| - | 16 | (strip\$3 ash\$3 remov\$3 etch\$3) with (resist photoresist) same (without near (solvent wet liquid rins\$3)) and (deposit\$4 near (conduct\$3 metal\$3 copper aluminum)) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:09 |
| - | 2 | ((US-6562700-\$ or US-6503840-\$ or US-6534921-\$ or US-6352938-\$ or US-6178660-\$ or US-6031239-\$).did. or (US-20020111041-\$ or US-20020185151-\$).did. or (TW-442916-\$).did.) and baffle | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2003/12/09 02:21 |